Towards Unification of Conservation Laws, Circuit Theory and Semiconductor Physics: A First-Principles Theory for Semiconductor Behaviors

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Abstract

Semiconductors are core component across all domains of electrical and electronic engineering (EEE), such as data centers,[1,2] electrified transportation,[3,4] robotics,[5] renewables[6,7] and grid applications,[8-10] etc. For example, transistors' switching behaviors govern energy loss, carbon emissions, water use, system lifetime, material use and cost etc. throughout EEE. Despite near a century since the transistor's invention,[11,12] switching remains poorly understood: treated as a black box and described empirically, it cannot be explained by conservation laws and circuit theory alone. Here we present a first-principles theory that extends conservation laws and circuit theory to semiconductors, enabling unification of conservation laws (i.e., laws of energy conversion and charge conversion), circuit theory (e.g., Ohm's laws and Kirchhoff's Laws) and semiconductor physics (e.g., the resistive components in the semiconductor and nonlinear junction capacitance variation due to the length variation of the drift region). Using this proposed theory, we revealed the physical origins and

fundamental mechanisms of switching phenomena, including the long-mysterious Miller plateau; we derived the proposed E_{on} prediction model, with errors of 0.88-11.60%, achieving a 17-fold average reduction compared to the state-of-the-art model (errors: 34.41- 80.05%). These results showcase the theory's unprecedented implications, enabling first-principles analysis, explanation and prediction replacing empirical and inaccurate understanding that have persisted for nearly a century.[11,12] This theory establishes a textbook-level foundation and opens directions across disciplines including materials science,[13,14] semiconductor physics,[15,16] device engineering,[17,18] packaging,[19,20] reliability,[21,22] thermal management,[2,23] power electronics,[24,25] computing and communications[26,27], and even sustainability sciences,[2,28,29] standards,[30] economics,[31] policy[32,33] and education.[34,35]

Keyword: semiconductor behavior, switching behavior, switching phenomena, proposed theory, switching loss, switching loss prediction, sustainability, electrical and electronic engineering

Introduction

Electrification, digitalization, and intelligentization are global megatrends placing unprecedented demands on electrical and electronic engineering (EEE). Across domains such as AI-driven data centers,[1,2] electrified transportation,[3,4] robotics,[5] renewable energy systems[6,7] and grid applications,[8,9] global electricity demands are projected to nearly double by 2050,[36] creating urgent challenges and calling for fundamentally more sustainable solutions. For example, energy supplies alone account for approximately 75% of global carbon emissions.[24] Most developments are ultimately underpinned by semiconductors – semiconductors' behaviors fundamentally govern efficiency, reliability, and sustainability etc., thereby shaping most applications.[37-41] For example, by 2030, 80% of the U.S. electricity is projected be processed by power electronics, based on semiconductors. [42]

Despite the central role, the understanding of semiconductors' behaviors has remained fragmented for nearly a century, dating back to the invention of the

transistor.[11,12] Taking turn-on as a representative example, circuit theory alone cannot explain the switching behavior; neither charge conservation nor energy conservation has been rigorously validated as a foundation for the switching analysis or E_{on} prediction. As a result, switching is treated as a black box, with analyses relying on inputs of observed waveforms, typically linearized waveforms approximated from empirical measurements,[34,35,43-45]. Consequently, the physical origins and fundamental mechanisms of switching phenomena remain only partially understood. For example, the cause of the well-known 'Miller platform'[34,35,43-52] as well as the voltage drop at the end of 'Miller platform' remains unclear.

A key reason is the lack of recognition of the influence of the complementary switch (CS)'s non-linear dynamics - switching is typically analyzed on the switch under study (SUS) alone.[34,35,43,44] Whilst prior works[45,46] identified the CS's overvoltage caused by HS of the SUS, the influence of CS's non-linear dynamics on the SUS's HS behavior remains unrecognized. Moreover, the unrecognized causal role of R_{S1} variation contributes to the fragmented understanding of switching phenomena, but also leaves the turn-on event without a clear criterion, potentially causing confusion in many cases. [34,35,43,44,51,53,54]

Perera et al.[48] and Kasper et al.[47] identified the SUS discharging and CS charging currents in ZCS and iZVS, respectively, pointing out the role of output capacitances in E_{on} modelling. Zhang et al.[51] pointed out the load inductor's contribution in the energy balance in double-pulse tests, whilst Kasper et al.[47] derived the conventional E_{on} model in iZVS scenario from energy conservation viewpoint. However, the influence of load current in iZVS, as well as the existence of CC and its associated dissipated energy remain beyond recognition, leading to their absence from the state-of-the-art E_{on} model[47]; the unification of energy and charge conservation remains unresolved.

To address these long-standing challenges, we propose a first-principles theory that transforms the understanding of semiconductor behaviors from empirical descriptions that have persisted for nearly a century[11,12] to one grounded solely in conservation laws and circuit theory. For the first time, the scope of conservation laws and circuit theory is extended to semiconductors, achieving a fundamental unification

of conservation laws, circuit theory and semiconductor physics in semiconductor behaviors. The proposed theory offers unprecedented analytical, explanatory and predictive power, identifying true physical boundaries and opening new directions for future research and applications. As demonstrations, it reveals, for the first time, physical origins and fundamental mechanisms in transistors' turn-on scenarios, including the physics underlying the famous "Miller platform"[34,35,43-52]; it also yields a new E_{on} prediction model with a 17-fold accuracy improvement over the state-of-the-art model.

As a textbook-level foundation, the proposed theory's implications include guiding studies in semiconductor materials science,[13,14] semiconductor physics[15,16], device engineering[17,18], packaging,[19,20] reliability,[21,22] thermal management,[2,23] power electronics[24,25] and even sustainability sciences,[2,28,29] standards,[30] economics,[31] policy[32,33] and education.[34,35] It is expected to support global sustainability by improving energy efficiency, cutting carbon emissions, extending lifetime, reducing material use and costs etc. across all domains of EEE.

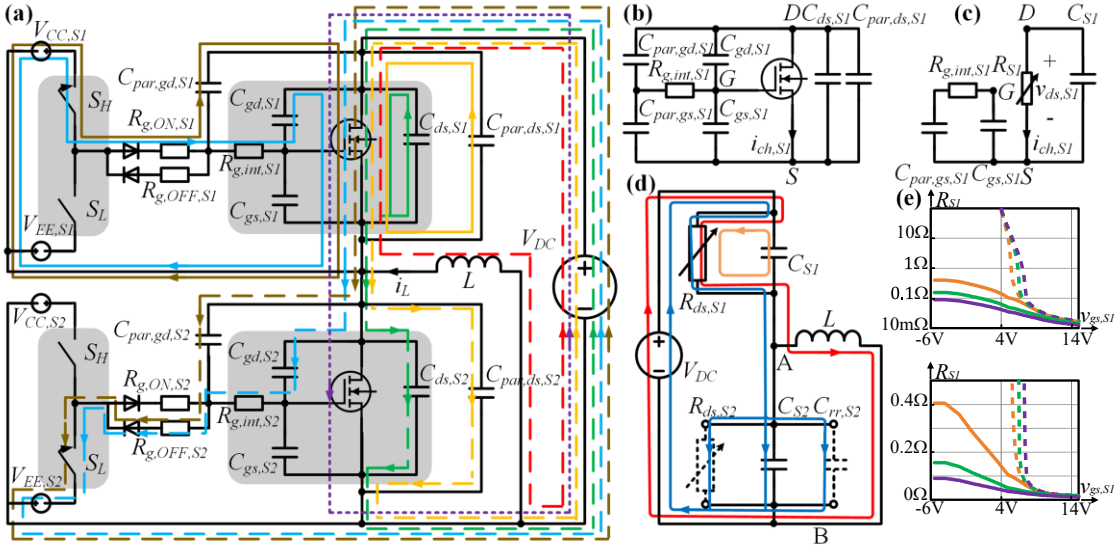


Figure 1. **(a)** Illustration of individual current components during VF when the load current flows out from the mid-point of the half-bridge during the entire iZVS process. **(b)** Conventional equivalent-circuit model of S_1. **(c)** Proposed equivalent-circuit model of S_1. **(d)** Simplified equivalent circuit of **(a)** using the proposed equivalent-circuit model for turn-on analysis. Potentially, when there is a shoot-through, $R_{ds,S2}$ is present; when there is a RR occurring in the VF, $C_{rr,S2}$ is present. **(e)** R_{S1} versus $v_{gs,S1}$ in forward (dashed) and reverse conduction (solid); orange, green and purple are for 10A, 30A and 60A conducting current, respectively: the upper sub-figure shows the behavior over the large gate-voltage range and the lower sub-figure highlights the low-resistance behavior.

The first-principles theory concept

The first-principles theory extends the scope of conservation laws and circuit theory by incorporating semiconductors' behaviors. Unlike conventional empirical descriptions, it enables rigorous causal analysis of semiconductor behaviors, serving as a three-way bridge for the long-sought unification of conservation laws, circuit theory, and semiconductor physics, and is universally applicable across device types and switching scenarios. The first-principles theory is grounded in the following foundational principles.

***Principle 1* (*P1*) — *Unified-Equivalent Principle*:** For any device type, switching scenario, and phase, a semiconductor can be reduced to its first-principles essence, i.e., a conductor with variable resistance and variable capacitance(s). Accordingly, a unified equivalent circuit — comprising variable resistances (e.g., R_{S1} and R_{S2}, detailed in *Methods*) and variable capacitances, including junction and reverse-recovery terms (e.g., C_{S1} and $C_{rr,S2}$, detailed in *Methods*) — provides a concise but effective representation that unifies circuit theory and semiconductor physics.

***Principle 2* (*P2*) — *First-Cause Principle*:** As the earliest and primary causal trigger, the rapid variation of R_{S1} initiates and drives the switching process. For example, the turn-on criterion is defined by $v_{gs,S1}$ exceeding $V_{th,S1}$ (detailed in *Methods*).

***Principle 3* (*P3*) — *Input–Boundary Principle*:** Characteristics of capacitances of both SUS and CS and the load's charge transfer and work are essential inputs that set the boundary conditions for the switching behavior. In particular, the transitions of CS's nonlinear junction capacitances and the existence of CC in iZVS with its associated dissipated energy, both of which beyond conventional recognition, are required to be explicitly included for accurate prediction and explanation (demonstrated in the following sections).

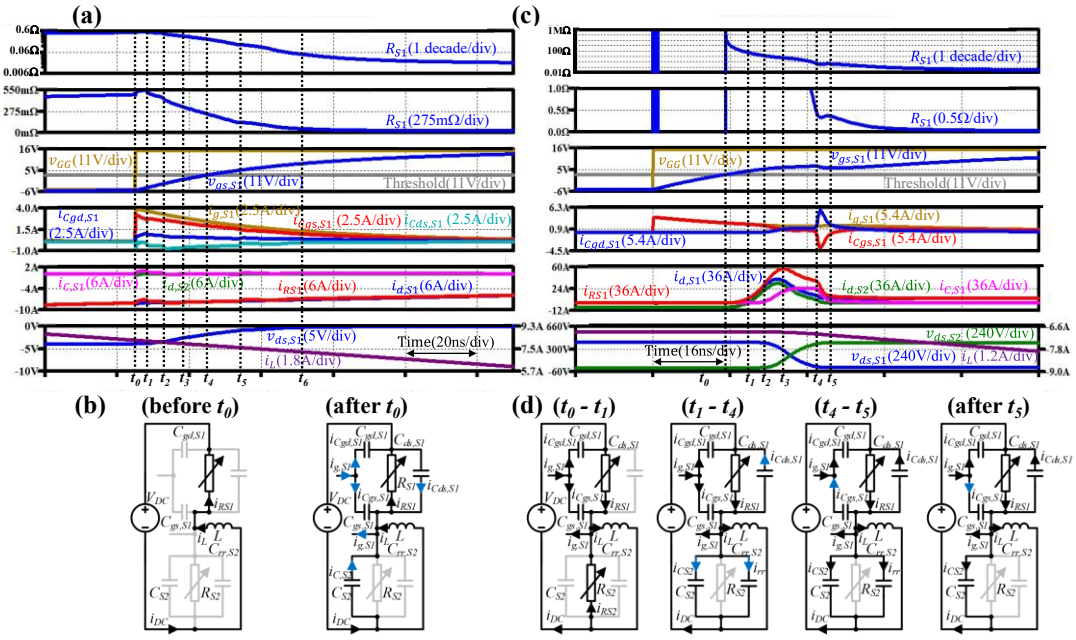


Figure 2. **(a)** Simulated waveforms during a typical ZVS process in LTspice. **(b)** The operation modes during a typical ZVS process. **(c)** Simulated waveforms during a typical HS process in LTspice. **(d)** The operation modes during a typical HS process.

First revelation of the physical origin and fundamental mechanism in Zero-Voltage-Switching (ZVS): demonstrating the proposed theory

Before t_0, i_L is reverse-conducted by S_1. During (t_0-t_1), as $v_{gs,S1}$<–4V, $v_{gs,S1}$ increase has negligible influence on R_{S1}; $i_{g,S1}$ charges $C_{gs,S1}$ and discharges $C_{gd,S1}$ simultaneously. Applying KCL at the mid-point yields $|i_{RS1}|+|i_{Cgd,S1}|=|i_L|+|i_{Cds,S1}|$. Since $|i_{Cgd,S1}|>|i_{Cds,S1}|$, $|i_{RS1}|<|i_L|$, explaining the observed drop in $|i_{RS1}|$, which causes a rise in R_{S1}. As $C_{ds,S1}$ is high and $i_{Cds,S1}$ is low, S_1's *dv/dt* of is low - $v_{ds,S1}$ remains nearly constant.

After t_1, as $v_{gs,S1}$>–4V, its increase causes R_{S1} to decrease, decreasing $v_{ds,S1}$, thereby building up both $i_{Cds,S1}$ and $i_{C,S2}$ via S_1's channel. During (t_2-t_3), R_{S1} falls most rapidly per unit rise in $v_{gs,S1}$, causing the quickest fall in $v_{ds,S1}$ and hence the peak $i_{Cds,S1}$. During (t_1-t_2) and (t_3-t_5), R_{S1} falls more slowly, leading to a slower fall in $v_{ds,S1}$ and secondary peaks in $i_{Cds,S1}$. After t_5, increasing $v_{gs,S1}$'s influence on reducing R_{S1} weakens further. As R_{S1} flattens, the midpoint voltage drops slightly, with a minor discharge of $C_{oss,S1}$ and C_{S2} via R_{S1}.

First revelation of the physical origin and fundamental mechanism of hard switching (HS): demonstrating the proposed theory

At t_0, i.e., the onset of HS, i_L is reverse-conducted by R_{S2}. During (t_0 - t_1), whilst $v_{ds,S1}$

remains nearly constant, with increasing $v_{gs,S1}$, R_{S1} decreases rapidly, increasing i_{RS1}. As a result, a lossy CC occurs during which i_L gradually commutates from R_{S2} to R_{S1}.

At t_1, i_L is entirely conducted by R_{S1}, indicating completion of the CC; a RR and a VF commence simultaneously, where the excessive carriers in S_2 is removed by the combined effects of recombination and $i_{d,S2}$, also known as reverse-recovery current. After t_1, $i_{d,S2}$ charges C_{S2} via R_{S1}, increasing $v_{ds,S2}$ and raising midpoint voltage. As S_1's drain voltage remains at the positive DC rail, $v_{ds,S1}$ drops, resulting in a discharging current through C_{S1} via R_{S1}. Notably, during (t_1-t_5), $|dv_{ds,S2}/dt|=i_{d,S2}/(C_{S2}+C_{rr,S2})$.

During (t_1-t_3), a quicker relative drop in R_{S1} compared to $v_{ds,S1}$ ($|dR_{S1}/R_{S1}|>|dv_{ds_S1}/v_{ds_S1}|$) causes a continued increase in i_{RS1}, increasing $i_{d,S2}$; meanwhile, as $v_{gs,S1}$ increases, $|dR_{S1}/R_{S1}|$ decreases, leading to a reduced di/dt of i_{RS1}.

During (t_1-t_2), although $C_{oss,S2}$ decreases and $i_{d,S2}$ increases, causing an increase in S_2's dv/dt, dv/dt remains low due to high $C_{oss,S2}$. Therefore, only a small portion of i_g is required by $C_{gd,S1}$ to track S_2's dv/dt, allowing most of i_g to charge $C_{gs,S1}$.

During (t_2-t_3), $C_{oss,S2}$ transitions from its high- to low-capacitance region, leading to an increase in S_2's dv/dt. As negative feedback, more i_g is diverted to $C_{gd,S1}$, leading to: (1) higher $i_{Cgd,S1}$, promoting $C_{gd,S1}$'s dv/dt; (2) lower $i_{Cgs,S1}$, which slows the increase in $v_{gs,S1}$, thereby slowing R_{S1} reduction and consequently slowing i_{RS1} increase. The slower i_{RS1} increase, combined with a significant increase in i_{CS1}, reduces the di/dt of $i_{d,S2}$ – initially positive then turning negative before t_3 – thus limiting increase in S_2's dv/dt despite decreasing $C_{oss,S2}$. As a result of the feedback, $C_{gd,S1}$'s dv/dt follows S_2's dv/dt.

During (t_3-t_4), the quicker relative reduction in $v_{ds,S1}$ than the relative reduction in R_{S1}, causes a decrease in i_{RS1}. Initially, as $C_{ds,S1}$ and $C_{gd,S1}$ increase whilst dv/dt changes insignificantly, $i_{C,S1}$ has a brief increase; more i_g is diverted to $C_{gd,S1}$. Both decreasing i_{RS1} and increasing $i_{C,S1}$ contribute to a decrease in $i_{d,S2}$. After that, i_{RS1} continues to drop, decreasing $i_{d,S2}$, which leads to a decreasing dv/dt. As dv/dt decreases whilst $C_{ds,S1}$ and $C_{gd,S1}$ increase, $i_{Cds,S1}$ and $i_{Cgd,S1}$ nearly stabilize.

During (t_4-t_5), as $v_{ds,S1}$ falls, $C_{gd,S1}$ enters its high-capacitance region and rises sharply. In contrast, as $v_{ds,S2}$ approaches V_{DC}, $C_{oss,S2}$ remains low, yet $i_{d,S2}$ sustains a significant dv/dt. Hence, $i_{Cgd,S1}$ must be sufficient to sustain a comparable dv/dt for $C_{gd,S1}$.

Consequently, limited i_g causes further negative feedback – a drop in $v_{gs,S1}$, which boosts i_g, strengthening $i_{Cgd,S1}$; simultaneously it causes R_{S1}'s rise, combined with $v_{ds,S1}$ reduction, lowering i_{RS1}, and suppressing $i_{d,S2}$ and thus S_2's *dv/dt*. Besides, a complementary current pulse from $C_{gs,S1}$ results to help discharge $C_{gd,S1}$ via R_{S1}. These effects ensure that $C_{gd,S1}$'s *dv/dt* follows S_2's *dv/dt*.

After t_5, as $v_{gs,S1}$ further increases, R_{S1} decreases slowly, causing a slight drop in mid-point voltage and consequently a minor discharge and charge of C_{S1} and C_{S2} via R_{S1}, respectively.

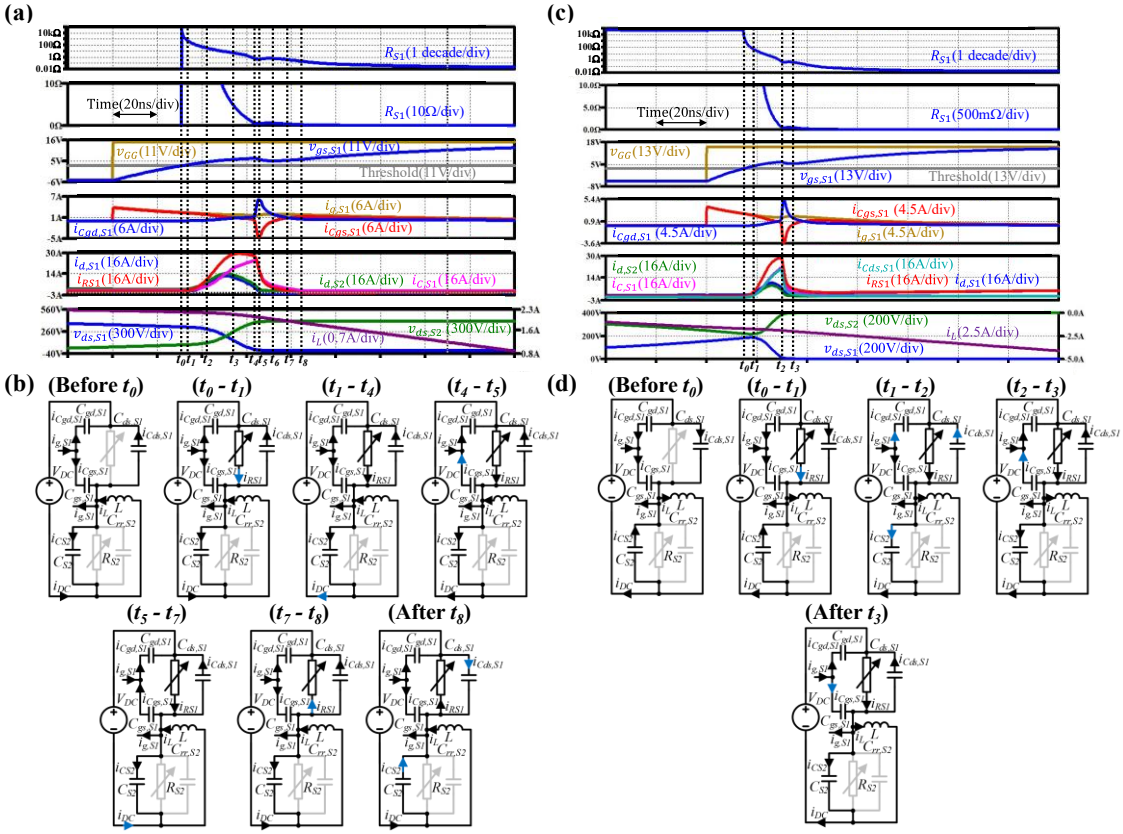


Figure 3. **(a)** Simulated waveforms during a typical iZVS process (case 1) in LTspice. **(b)** The operation modes during a typical iZVS process (case 1). **(c)** Simulated waveforms during a typical iZVS process (case 2) in LTspice. **(d)** The operation modes during a typical iZVS process (case 2).

First revelation of the physical origin and fundamental mechanism of Incomplete Zero-Voltage-Switching-ON (iZVS): demonstrating the proposed theory

Case 1: i_L flows into the half-bridge midpoint throughout the entire iZVS process

Before t_0, i.e., the onset, i_L discharges C_{S1} and charges C_{S2} simultaneously. During (t_0-t_1), the low $i_{d,S2}$ results in a low S_2's *dv/dt*, despite the low $C_{oss,S2}$. Consequently, only a small portion of i_g discharging $C_{gd,S1}$ is required to follow S_2's *dv/dt*, allowing most of

i_g to charge $C_{gs,S1}$. This leads to a significant increase in $v_{gs,S1}$, sharply reducing R_{S1}, consequently increasing i_{RS1} significantly. As a result, a lossy CC occurs, where the C_{S1}-conducted share of i_L commutates to C_{S2}. Unlike the near-zero *dv/dt* in the CC of HS, this CC features a non-zero *dv/dt* that increases with time due to the increasing i_{CS2} and decreasing $C_{oss,S2}$. At t_1, i_{RS1} exceeds $i_{C,S1}$, indicating the completion of the CC and triggering a reversal of i_{DC}'s direction.

During (t_1-t_2), $i_{RS1}+i_L=i_{d,S2}+i_{C,S1}$. Due to the initially high R_{S1}, i_{RS1} and thus $i_{d,S2}$ are low. As $v_{gs,S1}$ increases, R_{S1} decreases, increasing i_{RS1} and consequently $i_{d,S2}$. Unlike in (t_1-t_2) of the HS, the much lower $C_{oss,S2}$ leads to a higher *dv/dt*, which combined with the higher $C_{oss,S1}$, results in higher $i_{C,S1}$. This, in turn, limits $i_{d,S2}$'s increase, thereby slowing *dv/dt* rise. Consequently, only a small portion of i_g is diverted to discharge $C_{gd,S1}$ to follow S_2's *dv/dt*, whilst the majority charges $C_{gs,S1}$.

During (t_2-t_3), the continued increase in i_{RS1} leads to an increase in $i_{d,S2}$, consequently an increase in *dv/dt*. As negative feedback, more i_g is diverted to $C_{gd,S1}$, leading to two consequences: (1) higher $i_{Cgd,S1}$, promoting $C_{gd,S1}$'s *dv/dt*; (2) lower $i_{Cgs,S1}$, which slows the increase in $v_{gs,S1}$, thereby slowing R_{S1} reduction and consequently slowing i_{RS1} increase. The slower increase in i_{RS1}, combined with a significant increase in $i_{C,S1}$, reduces the *di/dt* of $i_{d,S2}$ – initially positive in (t_2-t_3), eventually becoming negative before t_3 - limiting increase in *dv/dt* despite the decreasing $C_{oss,S2}$. As a result of these combined effects, $C_{gd,S1}$ manages to follow S_2's *dv/dt*.

During (t_3-t_4), the quicker relative reduction in $v_{ds,S1}$ than the relative reduction in R_{S1}, causes a slight decrease in i_{RS1}, contributing to a decreasing $i_{d,S2}$. A significant increase in $C_{gd,S1}$ and $C_{ds,S1}$ causes an increase in $i_{Cgd,S1}$ and $i_{Cds,S1,}$ respectively, and thus the increase in $i_{C,S1}$, also contributing to the decrease in $i_{d,S2}$. Despite a slower relative drop in $C_{oss,S2}$, the significant decrease in $i_{d,S2}$ leads to a slight decrease in S_2's *dv/dt* and consequently a slight decrease in S_1's *dv/dt.* Hence, more i_g is diverted to discharge $C_{gd,S1}$, further slowing the increase of $v_{gs,S1}$ and thus slowing the reduction in R_{S1}.

During (t_4-t_6), $C_{gd,S1}$ is in its high-capacitance region, increasing rapidly as $v_{ds,S1}$ decreases; as $v_{ds,S2}$ approaches V_{DC}, $C_{oss,S2}$ remains low; as $i_{d,S2}$ remains significant, S_2's *dv/dt* remains significant. Consequently, $C_{gd,S1}$'s *dv/dt* has to remain significant. The

insufficient i_g to maintain $C_{gd,S1}$'s dv/dt to track S_2's dv/dt, triggers further negative feedback – a drop in $v_{gs,S1}$. This boosts i_g, enhancing $i_{Cgd,S1}$, but also increases R_{S1}, which combined with decreasing $v_{ds,S1}$, leads to a rapid reduction in i_{RS1}, and consequently a decreasing $i_{d,S2}$, thereby a lower dv/dt. Meanwhile, $C_{gs,S1}$ supplies a pulse current to help discharge $C_{gd,S1}$ via R_{S1}. Together, these effects enable $C_{gd,S1}$'s dv/dt to follow S_2's. Notably, at t_5, i_{RS1} drops below i_{CS1}, causing a direction reversal of i_{DC}.

During (t_6-t_8), $C_{gs,S1}$ stops supplying charge and is instead charged by i_g, which supplies charge to both $C_{gs,S1}$ and $C_{gd,S1}$. Notably, the mid-point voltage remains below V_{DC} before t_7 keeping I_{RS1} positive; after t_7, the mid-point voltage exceeds V_{DC}, reversing I_{RS1}'s direction. Meantime, the C_{S2}-conducted share of i_L gradually commutates to S_1. At t_8, the current commutation is completed and C_{S2} is fully charged, raising the mid-point voltage to $V_{DC}+R_{S1}(t_8)i_L(t_8)$. After t_8, as $v_{gs,S1}$ further increases, R_{S1} decreases slowly, causing a slight drop in mid-point voltage and consequently a minor discharge of C_{S1} and C_{S2} via R_{S1}.

Case 2: i_L flows out from the half-bridge midpoint throughout the entire iZVS process

Before t_0, i.e., the onset, i_L charges C_{S1} and discharges C_{S2} simultaneously. During (t_0-t_1), i_L continues to charge C_{S1} and discharge C_{S2} simultaneously; as $v_{gs,S1}>v_{th}$ and continues to increase, R_{S1} decreases, increasing i_{RS1}. Consequently, i_L gradually commutates to R_{S1}. At t_1, the entire i_L is conducted by R_{S1}.

During (t_1-t_2), initially, as $v_{gs,S1}$ continues to increase, R_{S1} decreases, increasing i_{RS1}, which increases i_{CS2}. Combined with lower $C_{oss,S2}$, it leads to a higher S_2's dv/dt. This triggers negative feedback: more i_g is diverted to $C_{gd,S1}$, causing (1) higher $i_{Cgd,S1}$, promoting $C_{gd,S1}$'s dv/dt; (2) lower $i_{Cgs,S1}$, slowing the increase in $v_{gs,S1}$, thereby slowing R_{S1} reduction and consequently slowing i_{RS1} increase. The slower increase in i_{RS1}, combined with a rapid increase in i_{CS1}, reduces the di/dt of $i_{d,S2}$ – initially positive, turning negative before t_3 - limiting dv/dt despite decreasing $C_{oss,S2}$. These combined effects enable $C_{gd,S1}$ to follow S_2's dv/dt.

During (t_2-t_3), $C_{gd,S1}$ is in the high-capacitance region, increasing rapidly as $v_{ds,S1}$ decreases; as $v_{ds,S2}$ approaches V_{DC}, $C_{oss,S2}$ remains low; as $i_{d,S2}$ remains significant, S_2's dv/dt remains significant. Consequently, $C_{gd,S1}$'s dv/dt has to remain significant. The

insufficient i_g to maintain $C_{gd,S1}$'s *dv/dt* to track S_2's *dv/dt*, triggers further negative feedback – a drop in $v_{gs,S1}$. This boosts i_g, enhancing $i_{Cgd,S1}$, but also increases R_{S1}, and with decreasing $v_{ds,S1}$, leading to a rapid reduction in i_{RS1}, and consequently a lower $i_{d,S2}$, thereby a lower *dv/dt*. Meanwhile, $C_{gs,S1}$ supplies a pulse current to help discharge $C_{gd,S1}$ via S_1's channel. Together, these effects enable $C_{gd,S1}$'s *dv/dt* to follow S_2's.

After t_3, $C_{gs,S1}$ stops supplying charge and is instead charged by i_g, which charges $C_{gs,S1}$ and $C_{gd,S1}$ simultaneously. As $v_{gs,S1}$ further increases, R_{S1} decreases slowly, causing a slight rise in midpoint voltage and consequently a minor discharge of C_{S1} and charge of C_{S2} via R_{S1}.

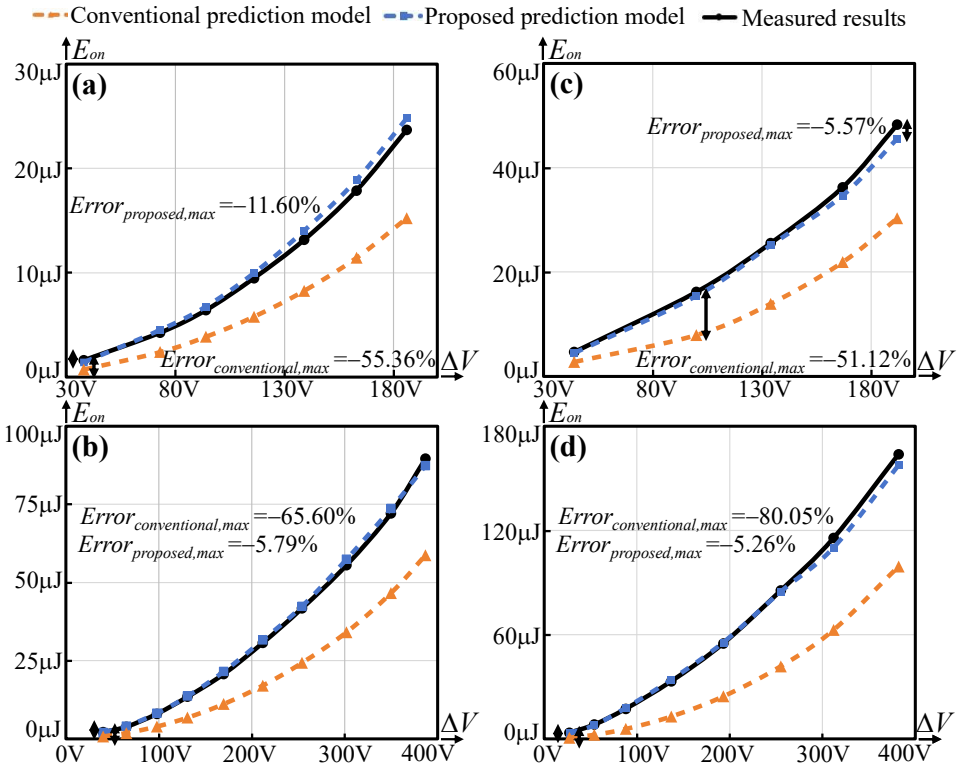


Figure 4. Comparison of measured results with calculated values using the proposed and conventional models, when CREE C2M0080120D is used; **(a)** V_{DC}=200 V. **(b)** V_{DC}=400 V. Comparison of measured results with calculated values using the proposed and conventional models, when CREE C2M0025120D is used; **(c)** V_{DC}=200 V. **(d)** V_{DC}=400 V.

Experimental validation

Enabled by the proposed theory, we derive an E_{on} prediction model for the case-2 iZVS scenario from charge and energy conservation, respectively (detailed in *Methods*). Experimental validation was performed by comparing measured results with calculated values obtained from both the proposed and conventional prediction models. Beyond

the conventional recognition, the proposed model incorporates previously unaccounted-for contributions, including the existence of the CC and associated dissipated energies in iZVS process, and load's charge transfer and work throughout the process. As a result, the proposed model achieves a 17-fold average error reduction compared to the conventional model.

Table 1. Detailed comparison of E_{on} measured results with calculated values using conventional and proposed prediction models, respectively

CREE 1.2Kv 2nd -gen SiC MOSFET (mΩ)	V_{DC} (V)	ΔV (V)	Measured results (μJ)	Calculated values using conventional prediction (μJ) (*Error*(conventional))	Calculated values using proposed prediction (μJ) (*Error*(proposed))	Error reduction |*Error*(conventional)/ *Error*(proposed)|
25	200	44	4.65	2.74 (–41.11%)	4.49 (–3.57%)	11.50
25	200	100	16.17	7.91 (–51.12%)	15.45 (–4.50%)	11.35
25	200	134	25.53	13.91 (–45.52%)	25.14 (–1.53%)	29.67
25	200	167	36.25	21.88 (–39.64%)	34.65 (–4.41%)	8.98
25	200	192	48.25	30.31 (–37.19%)	45.57 (–5.57%)	6.68
25	400	27	3.52	0.70 (–80.05%)	3.33 (–5.26%)	15.21
25	400	54	8.25	2.39 (–71.02%)	7.87 (–4.58%)	15.49
25	400	88	17.36	5.75 (–66.91%)	17.88 (2.95%)	22.66
25	400	137	33.21	12.91 (–61.11%)	34.14 (2.82%)	21.67
25	400	193	54.94	24.46 (–55.48%)	55.46 (0.94%)	58.75
25	400	255	85.42	41.79 (–51.08%)	84.67 (–0.88%)	57.75
25	400	312	115.68	62.76 (–45.75%)	110.10 (–4.82%)	9.49
25	400	382	163.86	99.24 (–39.44%)	157.42 (–3.93%)	10.02
80	200	38	1.59	0.709 (–55.36%)	1.40 (-11.60%)	4.77
80	200	73	4.24	2.38 (–43.78%)	4.50 (6.10%)	7.17
80	200	94	6.40	3.85 (–39.77%)	6.74 (5.40%)	7.37
80	200	116	9.47	5.78 (–38.91%)	9.96 (5.18%)	7.51
80	200	139	13.14	8.26 (–37.13%)	14.02 (6.70%)	5.54
80	200	163	17.88	11.42 (–36.11%)	18.87 (5.56%)	6.49
80	200	186	23.68	15.23 (–35.69%)	24.79 (4.69%)	7.61
80	400	40	2.17	0.748 (–65.60%)	2.05 (–5.79%)	11.33
80	400	65	3.89	1.82 (–53.14%)	4.06 (4.50%)	11.81
80	400	98	8.03	3.92 (–51.21%)	8.20 (2.12%)	24.13
80	400	131	13.50	6.77 (–49.82%)	13.66 (1.25%)	39.99
80	400	170	20.77	11.13 (–46.40%)	21.54 (3.73%)	12.45
80	400	212	30.73	17.05 (–44.53%)	31.65 (2.98%)	14.93
80	400	254	41.71	24.28 (–41.79%)	42.34 (1.51%)	27.70
80	400	302	55.54	34.10 (–38.61%)	57.40 (3.34%)	11.54
80	400	350	72.14	46.67 (–35.31%)	73.67 (2.11%)	16.70
80	400	387	89.57	58.75 (–34.41%)	87.35 (–2.49%)	13.85

Discussion

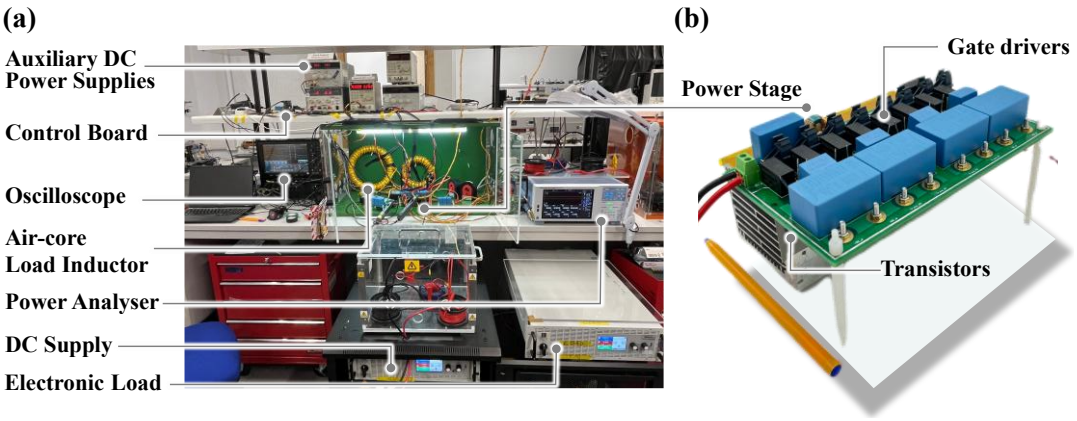
Using the first-principles theory, we have, for the first time, revealed physical

origins and fundamental mechanisms of ZVS, HS, case-1 iZVS, and case-2 iZVS, including the various origins of their Miller platforms (summarized in *Methods*); we have derived the proposed E_{on} prediction model for the case-2 iZVS scenario, which achieves, on average, a 17-fold error reduction compared to the conventional model; we have, for the first time, demonstrated the fundamental equivalence of the E_{on} prediction analyses based on conservation laws of energy and charge in *Methods*.

Together, these qualitative leaps demonstrate the effectiveness of this theory in extending the conservation laws and circuit theory to semiconductors and enabling the unification of conservation laws, circuit theory and semiconductor physics in semiconductor behaviors, which is central to the operation and performance of EEE. Showcased by these results, the paradigm opens a new window for first-ever discoveries and promises transformative advances—establishing a textbook-level foundation, opening broad directions and unlocking future breakthroughs.

Provided that semiconductor behaviors are universally relevant, this theory informs and drives immediate advances in research, design and optimization across domains in EEE. Its long-lasting impacts include stimulating follow-up studies and guiding applications across disciplines including semiconductor materials science,[13,14] semiconductor physics,[15,16] device engineering,[17,18] packaging,[19,20] reliability,[21,22] thermal management,[2,23] power electronics,[24,25] and even sustainability sciences,[2,28,29] standards,[30] economics,[31] policy[32,33] and education.[34,35] Together, the immediate and far-reaching impacts are expected to drive greener development in EEE and beyond.

Extended Data Figure - Experimental platform



Extended Data Fig. 1. Experimental platform for E_{on} measurement, using a power electronic converter as the demonstrative example. **(a)** Overview picture of the entire experimental platform for E_{on} measurement. **(b)** Close-up picture of converter power stage.

Methods

Nomenclature

Table 2. NOMENCLATURE

Symbol	Unit	Definition
S_x	N/A	Switch number, e.g., S_1 denotes the upper switch and S_2 denotes the lower switch
R_{Sx}	Ω	Equivalent resistance of S_x
$R_{drift,Sx}$	Ω	Drift-region resistance of S_x
$R_{ch,Sx}$	Ω	Channel resistance of S_x
$v_{ds,Sx}$	V	Drain-source voltage of S_x
v_{GG}	V	Output voltage of the gate driver of S_1
$V_{gs,Sx}$	V	Gate-source voltage of S_x
$V_{th,Sx}$	V	Threshold voltage of S_x
$C_{oss,Sx}$	pF	Output capacitance of S_x
C_{Sx}	pF	Overall equivalent capacitance of S_x
$C_{gs,Sx}$	pF	Gate-source capacitance of S_x
$C_{gd,Sx}$	pF	Gate-drain capacitance of S_x
$C_{ds,Sx}$	pF	Drain-source capacitance of S_x
$C_{par,Sx}$	pF	The equivalent capacitance of the associated parallel capacitances of $C_{oss,Sx}$
$C_{par,gs,Sx}$	pF	The equivalent capacitance of the associated parallel capacitances of $C_{gs,Sx}$
$C_{par,ds,Sx}$	pF	The equivalent capacitance of the associated parallel capacitances of $C_{oss,ds,Sx}$
$C_{par,gd,Sx}$	pF	The equivalent capacitance of the associated parallel capacitances of $C_{oss,gd,Sx}$
$i_{d,Sx}$	A	The drain current of S_x
$i_{g,Sx}$	A	Gate driving current of S_x
i_L	A	Load current
i_{RSx}	A	Instantaneous current through R_{Sx}
i_{DC}	A	DC-source current
$i_{Cgs,Sx}$	A	Displacement current of $C_{gs,Sx}$
$i_{Cgd,Sx}$	A	Displacement current of $C_{gd,Sx}$
$i_{Cds,Sx}$	A	Displacement current of $C_{ds,Sx}$
$i_{C,Sx}$	A	Displacement current of C_{Sx}

V_{DC}	V	DC-link voltage
T_{diss}	ns	Duration in which the dissipated energy is incurred
$E_{gd,Sx}(v)$	μJ	The energy stored in $C_{gd,Sx}$ at drain-gate voltage of v
$E_{ds,Sx}(v)$	μJ	The energy stored in $C_{ds,Sx}$ at drain-source voltage of v
$E_{oss,Sx}(v)$	μJ	The energy stored in the output capacitance of S_x at drain-source voltage of v
$Q_{oss,Sx}(v)$	nC	The charge stored in the output capacitance of S_x at drain-source voltage of v
Error(proposed)	N/A	Error of the proposed model's prediction results compared to the measured results
Error(conventional)	N/A	Error of the conventional model's prediction results compared to the measured results

The equivalent non-linear resistance model, i.e., R_{S1} model adopted in the proposed theory

In the proposed theory, a unified equivalent-circuit model incorporating only equivalent non-linear resistance(s) and equivalent non-linear capacitances is proposed for the transistor. Taking the MOSFET as an example, a non-linear equivalent resistance is defined by Ohm's law, $R_{S1}=v_{ds,S1}/i_{RS1}$ is proposed for S_1, where i_{RS1} includes all the current components except displacement currents across junction capacitances; R_{S1} incorporates all resistive components along the i_{RS1} paths, including equivalent resistance of body diode current path (during reverse conduction), JFET resistance, $R_{drift,S1}$, $R_{ch,S1}$ etc.

The R_{S1} model applies to all device types in both forward and reverse conduction operations, at any gate voltage. Its I-V characteristics in forward and reverse conduction follow the output characteristic and third-quadrant or body-diode characteristic of the transistor, respectively. At any given operating point, R_{S1} is given by the reciprocal of the slope of the line connecting the operating point and the origin of the I-V characteristic. The same R_{S2} model applies to S_2 - during shoot-through, an extra current component flows through R_{S2}.

The equivalent non-linear junction capacitances model adopted in the proposed theory

As the displacement current of $C_{gd,S1}$ flows through the drift region but not the channel, whereas that of $C_{ds,S1}$ flows through both, $C_{gd,S1}$ is modelled in parallel with $R_{drift,S1}$ whilst $C_{ds,S1}$ is modelled in parallel with R_{S1}. For simplicity, they are combined into a single lumped capacitance $C_{oss,S1}$ in parallel with R_{S1}. Their parallel capacitances

are grouped into another lumped capacitance in parallel with $C_{oss,S1}$, forming a single C_{S1} and C_{S2} for S_1 and S_2, respectively. The reverse-recovery effect is represented by a lumped non-linear capacitance, $C_{rr,S1}$ and $C_{rr,S2}$ in parallel with C_{S1} and C_{S2}, respectively. As no RR occurs in S_1 during its turn-on, $C_{rr,S1}$ is zero (open circuit); when RR of S_2 is absent, $C_{rr,S2}$ is also zero.

Criterion for the turn-on event defined in the proposed theory

Existing literature[34,35,43,44,51,53,54] lacks a clear criterion to identify turn-on events, potentially leading to mis-interpretation in scenarios including crosstalk-induced gate spikes,[51,53,54] multiple threshold crossings and multi-level gate-driving[54] etc. Hence, a criterion consistent with the proposed theory is introduced here - the onset is defined as the event that v_{gs} exceeds the threshold, triggering the initial dramatic reduction in R_{S1}. As all switching phenomena fundamentally originate from this $v_{gs,S1}$-driven R_{S1} reduction, the initial rapid drop of R_{S1} from infinity is identified as the starting point of the causal reasoning.

Case-2 iZVS E_{on} prediction model derivation based on the switching behavior revealed using the proposed theory

Derivation of the proposed E_{on} prediction model using the law of charge conservation

In all the turn-on scenarios, since the energy dissipated in the ESR of C_{S1} is negligible compared to that along the i_{RS1} paths[52,55] it is valid to assume that the entire $E_{on,S1}$ is incurred in R_{S1}. Hence, $E_{on,S1}$ is given by

$$E_{on,S1} = \int_{switching-ON} v_{ds,S1}(t) i_{RS1}(t) dt \,. \tag{1}$$

In case-2 iZVS process, as vast majority of the energy dissipation during S_1's turn-on is incurred during $(t_0 - t_3)$, it is valid to assume the dissipated energy incurred during $(t_0 - t_3)$ is $E_{on,S1}$.

Applying Kirchhoff's Current Law (KCL) at S_1's drain terminal, yielding

$$i_{RS1}(t) = i_{d,S1}(t) + i_{C_{gd},S1}(t) + i_{C_{ds},S1}(t) + i_{par,C_{gd},S1}(t) + i_{par,C_{ds},S1}(t) \,. \tag{2}$$

Substitute (2) into (1), yielding the expression of $E_{on,S1}$, given by

$$\begin{aligned} E_{on,S1} = & \int_{switching-ON} v_{ds,S1}(t) i_{d,S1}(t) dt + \int_{switching-ON} v_{ds,S1}(t) i_{C_{gd},S1}(t) dt + \int_{switching-ON} v_{ds,S1}(t) i_{C_{ds},S1}(t) dt \\ & + \int_{switching-ON} v_{ds,S1}(t) i_{par,C_{gd},S1}(t) dt + \int_{switching-ON} v_{ds,S1}(t) i_{par,C_{ds},S1}(t) dt \end{aligned} \,. \tag{3}$$

As $v_{gs,S1}$ during $(t_0 - t_3)$ is negligibly small compared to ΔV, it can be approximated as a constant V_{gp}; ΔV-V_{gp} can be approximated to ΔV and 0 V-V_{gp} can be approximated to 0 V. Therefore, the summation of 2nd, 3rd, 4th and 5th terms of the expression of $E_{on,S1}$ could be approximated as

$$\begin{aligned}
&\int_{switching-ON} v_{ds,S1}(t) i_{C_{gd},S1}(t)\,dt + \int_{switching-ON} v_{ds,S1}(t) i_{C_{ds},S1}(t)\,dt + \int_{switching-ON} v_{ds,S1}(t) i_{C_{par,gd},S1}(t)\,dt + \int_{switching-ON} v_{ds,S1}(t) i_{C_{par,ds},S1}(t)\,dt \\
&= \underbrace{E_{oss,S1}(\Delta V)}_{\text{Energy dissipated by output capacitance of S1}} + \underbrace{\int_{0-V_{gp}}^{\Delta V - V_{gp}} v_{ds,S1} C_{par,gd,S1}(v_{gd,S1})\,dv_{gd,S1}}_{\text{Energy dissipated by capacitance in parallel with } C_{gd,S1}} + \underbrace{\int_{0}^{\Delta V} v_{ds,S1} C_{par,ds,S1}\,dv_{ds,S1}}_{\text{Energy dissipated by capacitance in parallel with } C_{ds,S1}} \\
&\approx \underbrace{E_{oss,S1}(\Delta V)}_{\text{Energy dissipated by output capacitance of S1}} + \underbrace{\int_{0}^{\Delta V} v_{ds,S1} C_{par,gd,S1}(v_{gd,S1})\,dv_{gd,S1}}_{\text{Energy dissipated by capacitance in parallel with } C_{gd,S1}} + \underbrace{\int_{0}^{\Delta V} v_{ds,S1} C_{par,ds,S1}\,dv_{ds,S1}}_{\text{Energy dissipated by capacitance in parallel with } C_{ds,S1}} \\
&= \underbrace{E_{oss,S1}(\Delta V)}_{\text{Energy dissipated in RS1 due to discharge of S1's output capacitance}} + \underbrace{\frac{1}{2} C_{par,S1} \Delta V^2}_{\text{Energy dissipated in RS1 due to discharge of S1's paralleled capacitance}}
\end{aligned} \quad .(4)$$

Besides, the charge obtained by $C_{gd,S2}$, $C_{ds,S2}$ and the charge obtained by their paralleled capacitances during $(t_0 - t_3)$, are given by

$$\begin{aligned}
\Delta Q_{S2} &= \int_{switching-ON} i_{Cgd,S2}(t)\,dt + \int_{switching-ON} i_{Cds,S2}(t)\,dt \\
&= \int_{V_{DC}-\Delta V-(-V_{EE})}^{V_{DC}-(-V_{EE})} C_{gd,S2}\,dv_{gd,S2} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{ds,S2}\,dv_{ds,S2} \\
&\approx \int_{V_{DC}-\Delta V}^{V_{DC}} C_{gd,S2}\,dv_{gd,S2} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{ds,S2}\,dv_{ds,S2} \\
&= Q_{oss,S2}(V_{DC}) - Q_{oss,S2}(V_{DC}-\Delta V)
\end{aligned} \quad ; \quad (5)$$

$$\begin{aligned}
&\int_{(V_{DC}-\Delta V)-(-V_{EE})}^{V_{DC}-(-V_{EE})} C_{par,gd,S2}(v_{gd})\,dv_{gd} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{par,ds,S2}(v_{ds})\,dv_{ds} \\
&\approx \int_{V_{DC}-\Delta V}^{V_{DC}} C_{par,gd,S2}(v_{gd})\,dv_{gd} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{par,ds,S2}(v_{ds})\,dv_{ds} \\
&= \left[\int_{0}^{V_{DC}} C_{par,gd,S2}(v_{gd})\,dv_{gd} - \int_{0}^{V_{DC}-\Delta V} C_{par,gd,S2}(v_{gd})\,dv_{gd}\right] + \left[\int_{0}^{V_{DC}} C_{par,ds,S2}(v_{ds})\,dv_{ds} - \int_{0}^{V_{DC}-\Delta V} C_{par,ds,S2}(v_{ds})\,dv_{ds}\right] \\
&= C_{par,gd,S2}\Delta V + C_{par,ds,S2}\Delta V \\
&= C_{par,S2}\Delta V
\end{aligned}$$

.(6)

Applying Kirchhoff's Voltage Law (KVL) across the loop incorporating the DC source, S1 and S2, yielding

$$V_{DC} = v_{ds,S1}(t) + v_{ds,S2}(t). \quad (7)$$

Applying KCL at the source terminal of S_2, yielding

$$i_{DC}(t) = i_{d,S2}(t) - i_L(t) = i_{RS2}(t) + i_{C,S2}(t) - i_L(t). \quad (8)$$

Hence, the 1st term of the expression of $E_{on,S1}$ could be derived as

$$\begin{aligned}&\int_{switching-ON} v_{ds,S1}(t)i_{d,S1}(t)dt\\&=\int_{switching-ON} V_{DC}i_{DC}(t)dt-\int_{switching-ON} v_{ds,S2}(t)\left[i_{d,S2}(t)-i_L(t)\right]dt\\&=V_{DC}\int_{switching-ON}\left[i_{RS2}(t)+i_{C,S2}(t)-i_L(t)\right]dt-\int_{switching-ON} v_{ds,S2}(t)i_{d,S2}(t)dt+\int_{switching-ON} v_{ds,S2}(t)i_L(t)dt\end{aligned} \quad . \quad (9)$$

where

$$\begin{aligned}\int_{switching-ON} v_{ds,S2}(t)i_{d,S2}(t)dt=&\underbrace{\int_{(V_{DC}-\Delta V)-(-V_{EE})}^{V_{DC}-(-V_{EE})} v_{gd,S2}C_{gd,S2}\left(v_{gd,S2}\right)dv_{gd,S2}}_{Energy\ \ stored\ \ by\ \ C_{gd,S2}}+\underbrace{\int_{V_{DC}-\Delta V}^{V_{DC}} v_{ds,S2}C_{ds,S2}\left(v_{ds,S2}\right)dv_{ds,S2}}_{Energy\ \ stored\ \ by\ \ C_{ds,S2}}\\&+\underbrace{\int_{(V_{DC}-\Delta V)-(-V_{EE})}^{V_{DC}-(-V_{EE})} v_{gd,S2}C_{par,gd,S2}\left(v_{gd,S2}\right)dv_{gd,S2}}_{Energy\ \ stored\ \ by\ \ C_{gd,S2}\text{'s paralleled capacitance}}+\underbrace{\int_{V_{DC}-\Delta V}^{V_{DC}} v_{ds,S2}C_{ds,S2}\left(v_{ds,S2}\right)dv_{ds,S2}}_{Energy\ \ stored\ \ by\ \ C_{ds,S2}\text{'s paralleled capacitance}}+\underbrace{\int_{switching-ON} v_{ds,S2}(t)i_{RS2}(t)dt}_{Energy\ \ dissipation\ \ in\ \ S2\ \ due\ \ to\ \ shoot-through}\end{aligned} \quad .(10)$$

(10) could be approximated to

$$\begin{aligned}&\int_{switching-ON} v_{ds,S2}(t)i_{d,S2}(t)dt\\&\approx\underbrace{\int_{V_{DC}-\Delta V}^{V_{DC}} v_{gd,S1}C_{gd,S2}\left(v_{gd,S2}\right)dv_{gd,S2}}_{Energy\ \ stored\ \ by\ \ C_{gd,S2}}+\underbrace{\int_{V_{DC}-\Delta V}^{V_{DC}} v_{ds,S2}C_{ds,S2}\left(v_{ds,S2}\right)dv_{ds,S2}}_{Energy\ \ stored\ \ by\ \ C_{ds,S2}}+\underbrace{\int_{V_{DC}-\Delta V}^{V_{DC}} v_{gd,S1}C_{par,gd,S2}\left(v_{gd,S2}\right)dv_{gd,S2}}_{Energy\ \ stored\ \ by\ \ C_{gd,S2}\text{'s paralleled capacitance}}\\&+\underbrace{\int_{V_{DC}-\Delta V}^{V_{DC}} v_{ds,S2}C_{par.ds,S2}\left(v_{ds,S2}\right)dv_{ds,S2}}_{Energy\ \ stored\ \ by\ \ C_{ds,S2}\text{'s paralleled capacitance}}+\underbrace{\int_{switching-ON} v_{ds,S2}(t)i_{RS2}(t)dt}_{Energy\ \ dissipation\ \ in\ \ S2\ \ due\ \ to\ \ shoot-through}\\&=\underbrace{E_{oss,S2}(V_{DC})-E_{oss,S2}(V_{DC}-\Delta V)}_{Energy\ \ stored\ \ by\ \ C_{oss,S2}}+\underbrace{\frac{1}{2}(C_{par,gd,S2}+C_{par,ds,S2})\left[{V_{DC}}^2-(V_{DC}-\Delta V)^2\right]}_{Energy\ \ stored\ \ by\ \ the\ \ paralleled\ \ capacitance\ \ of\ \ S2}+\underbrace{\int_{switching-ON} v_{ds,S2}(t)i_{RS2}(t)dt}_{Energy\ \ dissipation\ \ in\ \ S2\ \ due\ \ to\ \ shoot-through}\\&=\underbrace{E_{oss,S2}(V_{DC})-E_{oss,S2}(V_{DC}-\Delta V)}_{Energy\ \ stored\ \ by\ \ C_{oss,S2}}+\underbrace{\frac{1}{2}C_{par,S2}\left[{V_{DC}}^2-(V_{DC}-\Delta V)^2\right]}_{Energy\ \ stored\ \ by\ \ the\ \ paralleled\ \ capacitance\ \ of\ \ S2}+\underbrace{\int_{switching-ON} v_{ds,S2}(t)i_{RS2}(t)dt}_{Energy\ \ dissipation\ \ in\ \ S2\ \ due\ \ to\ \ shoot-through}\end{aligned} \quad .(11)$$

It is important to note that

$$\int_{switching-ON} i_{C,S2}(t)dt=\Delta Q_{S2}+C_{par,S2}\Delta V \ . \quad (12)$$

Combining (3)(4)(5)(6)(7)(8)(9)(10)(11)(12), yielding the $E_{on,S1}$ prediction model derived from the perspective of charge conservation, given by

$$\begin{aligned}E_{on,S1}\approx&\underbrace{V_{DC}\left[\int_{switching-ON} i_{RS2}(t)dt+\Delta Q_{S2}+C_{par,S2}\Delta V-\int_{switching-ON} i_L(t)dt\right]}_{Energy\ \ provided\ \ by\ \ DC\ \ source\ \ to\ \ the\ \ half-bridge}+\underbrace{\int_{switching-ON} v_{ds,S2}(t)i_L(t)dt}_{Energy\ \ provided\ \ by\ \ the\ \ overall\ \ AC-link\ \ impedance\ \ to\ \ the\ \ half-bridge}\\&-\underbrace{\left[E_{oss,S2}(V_{DC})-E_{oss,S2}(V_{DC}-\Delta V)\right]}_{Energy\ \ stored\ \ by\ \ output\ \ capacitance\ \ of\ \ S2}-\underbrace{\int_{switching-ON} v_{ds,S2}(t)i_{RS2}(t)dt}_{Energy\ \ dissipated\ \ in\ \ S2\ \ due\ \ to\ \ shoot-through}-\underbrace{\frac{1}{2}C_{par,S2}\left[{V_{DC}}^2-(V_{DC}-\Delta V)^2\right]}_{Energy\ \ stored\ \ by\ \ the\ \ paralleled\ \ capacitance\ \ of\ \ S2}\\&+\underbrace{E_{oss,S1}(\Delta V)+\frac{1}{2}C_{par,S1}\Delta V^2}_{Energy\ \ dissipated\ \ in\ \ RS1\ \ due\ \ to\ \ discharge\ \ of\ \ S1\text{'s output capacitance and paralleled capacitance}}\end{aligned} \quad .(13)$$

Derivation of the proposed E_{on} prediction model using the law of energy conservation

The half-bridge during the S1's turn-on process is taken as the study object. For simplicity reasons, the analysis is limited to (t_0 – t_3) as vast majority of the energy dissipation during S_1's turn-on is incurred during this interval. According to the law of

energy conservation, the overall energy initially stored in the study object, minus the various dissipated energies incurred during the turn-on process and the energy delivered to the external circuit, yields the remaining stored energy at the end of the interval. The general mathematical expression is given by

$$E_{initial} - E_{dissipated} - E_{delivered} = E_{final}, \tag{14}$$

where $E_{initial}$ denotes the overall energy stored in the study object at the initial instant; $E_{dissipated}$ denotes the total energy losses during S_1's turn-on process, including but not limited to turn-on loss and ESR losses; $E_{delivered}$ denotes the energy delivered to the external circuit; E_{final} denotes the total energy stored in the study object at the end of the process. Among them, $E_{initial}$ and E_{final} are given by

$$\begin{aligned}
E_{initial} &= \left[E_{gd,S1}\left(\Delta V - v_{gs,S1}(t_0)\right) + E_{ds,S1}(\Delta V) + \frac{1}{2}C_{par,gd,S1}\left(\Delta V - v_{gs,S1}(t_0)\right)^2 + \frac{1}{2}C_{par,ds,S1}\Delta V^2 \right] \\
&+ \left[E_{gd,S2}\left(V_{DC} - \Delta V - v_{gs,S2}(t_0)\right) + E_{ds,S2}(V_{DC} - \Delta V) + \frac{1}{2}C_{par,gd,S2}\left(V_{DC} - \Delta V - v_{gs,S2}(t_0)\right)^2 + \frac{1}{2}C_{par,ds,S2}(V_{DC} - \Delta V)^2 \right] \quad ; \\
&= \left[E_{gd,S1}\left(\Delta V - V_{th,S1}\right) + E_{ds,S1}(\Delta V) + \frac{1}{2}C_{par,gd,S1}\left(\Delta V - V_{th,S1}\right)^2 + \frac{1}{2}C_{par,ds,S1}\Delta V^2 \right] \\
&+ \left[E_{gd,S2}\left(V_{DC} - \Delta V - v_{gs,S2}(t_0)\right) + E_{ds,S2}(V_{DC} - \Delta V) + \frac{1}{2}C_{par,gd,S2}\left(V_{DC} - \Delta V - v_{gs,S2}(t_0)\right)^2 + \frac{1}{2}C_{par,ds,S2}(V_{DC} - \Delta V)^2 \right]
\end{aligned} \tag{15}$$

$$\begin{aligned}
E_{final} &= \left[E_{gd,S1}\left(-V_{th,S1}\right) + E_{ds,S1}(0) + \frac{1}{2}C_{par,gd,S1}\left(0 - V_{th,S1}\right)^2 + \frac{1}{2}C_{par,ds,S1}0^2 \right] \\
&+ \left[E_{gd,S2}\left(V_{DC} - v_{gs,S2}(t_0)\right) + E_{ds,S2}(V_{DC}) + \frac{1}{2}C_{par,gd,S2}\left(V_{DC} - v_{gs,S2}(t_0)\right)^2 + \frac{1}{2}C_{par,ds,S2}{V_{DC}}^2 \right],
\end{aligned} \tag{16}$$

where $v_{gs,S1}(t_0)=V_{th,S1}$. As both $v_{gs,S1}$ and $v_{gs,S2}$ during the process are negligibly small compared to ΔV and V_{DC}-ΔV, both $v_{gs,S1}$ and $v_{gs,S2}$ can be approximated to 0 V, yielding

$$\begin{aligned}
E_{initial} &\approx \left[E_{gd,S1}(\Delta V) + E_{ds,S1}(\Delta V) + \frac{1}{2}C_{par,gd,S1}(\Delta V)^2 + \frac{1}{2}C_{par,ds,S1}\Delta V^2 \right] \\
&+ \left[E_{gd,S2}(V_{DC} - \Delta V) + E_{ds,S2}(V_{DC} - \Delta V) + \frac{1}{2}C_{par,gd,S2}(V_{DC} - \Delta V)^2 + \frac{1}{2}C_{par,ds,S2}(V_{DC} - \Delta V)^2 \right]; \\
&= \left[E_{oss,S1}(\Delta V) + \frac{1}{2}C_{par,S1}(\Delta V)^2 \right] + \left[E_{oss,S2}(V_{DC} - \Delta V) + \frac{1}{2}C_{par,S2}(V_{DC} - \Delta V)^2 \right]
\end{aligned} \tag{17}$$

$$\begin{aligned}
E_{final} &\approx E_{gd,S2}(V_{DC}) + E_{ds,S2}(V_{DC}) + \frac{1}{2}C_{par,gd,S2}{V_{DC}}^2 + \frac{1}{2}C_{par,ds,S2}{V_{DC}}^2 \\
&= E_{oss,S2}(V_{DC}) + \frac{1}{2}C_{par,S2}{V_{DC}}^2
\end{aligned}. \tag{18}$$

During S_1's iZVS process , the energy dissipation caused by ESR is negligible compared to $E_{dissipated}$. The dominant dissipated energy arises from $E_{on,S1}$ and the dissipated energy within S_2 due to the shoot-through effect. Hence, $E_{dissipated}$ can be approximated as

consisting only of these two components, namely

$$E_{dissipated} \approx E_{on,S1} + E_{dissipated,S2}, \tag{19}$$

where $E_{dissipated,S2} = \underbrace{\int_{switching-ON} v_{ds,S2}(t) i_{RS2}(t) dt}_{Energy\ \ dissipated\ \text{in}\ S2\ \ due\ \ to\ \ shoot-through}$. (20)

Regarding the energy delivered to the external circuit, $E_{delivered}$ could be obtained as

$$E_{delivered} = -(W_{DC} + W_L) \tag{21}$$

where W_{DC} and W_L denote the work done by the DC source and load inductor to the study object, respectively.

In order to obtain W_{DC}, it is important to obtain the total charge obtained by the DC source, denoted ΔQ_{DC} during the process. Applying KCL at S_2's source terminal, yielding

$$i_{DC}(t) = i_{d,S2}(t) - i_L(t) = i_{C,S2}(t) + i_{RS2}(t) - i_L(t). \tag{22}$$

Integrating both sides of (22), yielding

$$\Delta Q_{DC} = \int_{switching-ON} i_{DC}(t) dt = \int_{switching-ON} i_{C,S2}(t) dt + \int_{switching-ON} i_{R,S2}(t) dt - \int_{switching-ON} i_L(t) dt, \tag{23}$$

where

$$\begin{aligned}
&\int_{switching-ON} i_{C,S2}(t) dt \\
&= \int_{switching-ON} i_{Cgd,S2}(t) dt + \int_{switching-ON} i_{Cds,S2}(t) dt + \int_{switching-ON} i_{Cpar,gd,S2}(t) dt + \int_{switching-ON} i_{Cpar,ds,S2}(t) dt \\
&= \int_{switching-ON} C_{gd,S2} \frac{dv_{gd,S2}}{dt} dt + \int_{switching-ON} C_{ds,S2} \frac{dv_{ds,S2}}{dt} dt \\
&+ \int_{switching-ON} C_{par,gd,S2} \frac{dv_{gd,S2}}{dt} dt + \int_{switching-ON} C_{par,ds,S2} \frac{dv_{ds,S2}}{dt} dt \\
&= \int_{V_{DC}-\Delta V-v_{gs,S2}(t_0)}^{V_{DC}-v_{gs,S2}(t_3)} C_{gd,S2} dv_{gd,S2} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{ds,S2} dv_{ds,S2} \\
&+ \int_{V_{DC}-\Delta V-v_{gs,S2}(t_0)}^{V_{DC}-v_{gs,S2}(t_3)} C_{par,gd,S2} dv_{gd,S2} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{par,ds,S2} dv_{ds,S2}
\end{aligned} \tag{24}$$

As $v_{gs,S2}$ is negligibly small compared to V_{DC}-ΔV during the process, (24) could be approximated to

$$\begin{aligned}
&\int_{switching-ON} i_{C,S2}(t) dt \\
&\approx \int_{V_{DC}-\Delta V}^{V_{DC}} C_{gd,S2} dv_{gd,S2} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{ds,S2} dv_{ds,S2} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{par,gd,S2} dv_{gd,S2} + \int_{V_{DC}-\Delta V}^{V_{DC}} C_{par,ds,S2} dv_{ds,S2} \\
&= Q_{oss,S2}(V_{DC}) - Q_{oss,S2}(V_{DC} - \Delta V) + (C_{par,gd,S2} + C_{par,ds,S2}) \Delta V \\
&= \Delta Q_{S2} + C_{par,S2} \Delta V
\end{aligned} \tag{25}$$

Therefore, ΔQ_{DC} is obtained as

$$\Delta Q_{DC} \approx \Delta Q_{S2} + C_{par,S2} \Delta V + \int_{switching-ON} i_{RS2}(t) dt - \int_{switching-ON} i_L(t) dt. \tag{26}$$

Hence, W_{DC} is obtained as

$$W_{DC} = \int_{switching-ON} V_{DC} i_{DC}(t)dt = V_{DC}\Delta Q_{DC}$$
$$= V_{DC}\left[\Delta Q_{S2} + C_{par,S2}\Delta V + \int_{switching-ON} i_{RS2}(t)dt - \int_{switching-ON} i_L(t)dt\right]. \quad (27)$$

In terms of the work done by the load inductor W_L, it could be obtained as

$$W_L = \int_{switching-ON} v_L(t) i_L(t)dt = \int_{switching-ON} v_{ds,S2}(t) i_L(t)dt \quad (28)$$

Substituting (27) and (28) into (21), yielding

$$E_{delivered} = -(W_{DC} + W_L) =$$
$$= -V_{DC}\left[\Delta Q_{S2} + C_{par,S2}\Delta V + \int_{switching-ON} i_{RS2}(t)dt - \int_{switching-ON} i_L(t)dt\right] - \int_{switching-ON} v_{ds,S2}(t) i_L(t)dt \quad (29)$$

Substituting (17),(18),(19),(20),(29) into (14), yielding the $E_{on,S1}$ prediction model, given by

$$E_{on,S1} \approx \underbrace{V_{DC}\left[\int_{switching-ON} i_{RS2}(t)dt + \Delta Q_{S2} + C_{par,S2}\Delta V - \int_{switching-ON} i_L(t)dt\right]}_{Energy\ provided\ by\ DC\ source\ to\ the\ half-bridge} + \underbrace{\int_{switching-ON} v_{ds,S2}(t) i_L(t)dt}_{Energy\ provided\ by\ the\ load\ inductor\ to\ the\ half-bridge}$$
$$- \underbrace{\left[E_{oss,S2}(V_{DC}) - E_{oss,S2}(V_{DC} - \Delta V)\right]}_{Energy\ stored\ by\ output\ capacitance\ of\ S2} - \underbrace{\int_{switching-ON} v_{ds,S2}(t) i_{RS2}(t)dt}_{Energy\ dissipated\ in\ S2\ due\ to\ shoot-through} - \underbrace{\frac{1}{2}C_{par,S2}\left[V_{DC}{}^2 - (V_{DC} - \Delta V)^2\right]}_{Energy\ stored\ by\ the\ paralleled\ capacitance\ of\ S2} \quad .(30)$$
$$+ \underbrace{E_{oss,S1}(\Delta V) + \frac{1}{2}C_{par,S1}\Delta V^2}_{Energy\ dissipated\ in\ RS1\ due\ to\ discharge\ of\ S1's\ output\ capacitance\ and\ paralleled\ capacitance}$$

It is noteworthy that (30) is identical to (13), indicating that the proposed prediction model derived using the law of energy conservation is fundamentally equivalent to that derived using the law of charge conservation, whilst both derivations are grounded in the proposed first-principles theory.

For the first time, this equivalence cross-validates the proposed E_{on} prediction model, showcases the applicability of both physical laws in the domain of semiconductor behavior and establishes a fundamental unification of the laws of charge and energy conservation in this domain.

Summary of turn-on scenarios

Table 3. Summary of switching behaviors in switching scenarios

Switching scenario	ZVS	HS	Case-1 iZVS	Case-2 iZVS
1st phase	CC	CC	CC	CC
2nd phase	N/A	VF and RR	VF	VF
Miller platform existence	NO	YES	YES	YES
1st sub-phase of Miller platform; associated physical origin	N/A	(t_1-t_2); high $C_{oss,S2}$ and low $i_{d,S2}$, causing low dv/dt, thus low $i_{Cgd,S1}$	(t_1-t_2); high $C_{oss,S2}$ and low $i_{d,S2}$, causing low dv/dt; as $C_{gd,S1}$ is also low, $i_{Cgd,S1}$ is low	(t_1-t_2); medium-to-low $C_{oss,S2}$ and high $i_{d,S2}$, causing high dv/dt; as $C_{gd,S1}$ is

				medium-to-high, $i_{Cgd,S1}$ is high
2nd sub-phase of Miller platform; associated physical origin	N/A	(t_2-t_3); medium $C_{oss,S2}$ and high $i_{d,S2}$, causing medium dv/dt; given low $C_{gd,S1}$, low-to-medium $i_{Cgd,S1}$ results	(t_2-t_3); medium $C_{oss,S2}$ and high $i_{d,S2}$, causing medium dv/dt; given low-to-medium $C_{gd,S1}$, low-to-medium $i_{Cgd,S1}$ results	(t_2-t_3); low $C_{oss,S2}$ and decreasing $i_{d,S2}$, causing high-to-low dv/dt; as $C_{gd,S1}$ is high, $i_{Cgd,S1}$ is high-to-low
3rd sub-phase of Miller platform; associated physical origin	N/A	(t_3-t_4); $\lvert dR_{S1}/R_{S1}\rvert > \lvert dv_{ds_S1}/v_{ds_S1}\rvert$ causes decreasing i_{RS1}, and thus a decreasing $i_{d,S2}$, leading to a decreasing dv/dt, whilst $C_{gd,S1}$ increases, causing nearly unchanged $i_{Cgd,S1}$ at medium level	(t_3-t_4); medium-to-low $C_{oss,S2}$ and decreasing $i_{d,S2}$, causing decreasing dv/dt; given increasing $C_{gd,S1}$, nearly unchanged $i_{Cgd,S1}$ results	
4th sub-phase of Miller platform; associated physical origin	N/A	(t_4-t_5); high $C_{gd,S1}$ and medium dv/dt, causing high $i_{Cgd,S1}$	(t_4-t_6); high $C_{gd,S1}$ and medium dv/dt, causing high $i_{Cgd,S1}$	

Data availability

The data presented in this study are available in this manuscript.

Code availability

No custom code was used in this study.

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The authors declare no competing interests.

Supplementary Information

N/A